

Notice of References Cited	Application/Control No. 10/019,458	Applicant(s)/Patent Under Reexamination GORDON ET AL.	
	Examiner Joseph D. Anthony	Art Unit 1714	Page 1 of 1

U.S. PATENT DOCUMENTS

*		Document Number Country Code-Number-Kind Code	Date MM-YYYY	Name	Classification
	A	US-5,145,855	09-1992	Kosley et al.	514/269
	B	US-6,806,004	10-2004	Iwamoto et al.	429/313
	C	US-			
	D	US-			
	E	US-			
	F	US-			
	G	US-			
	H	US-			
	I	US-			
	J	US-			
	K	US-			
	L	US-			
	M	US-			

FOREIGN PATENT DOCUMENTS

*		Document Number Country Code-Number-Kind Code	Date MM-YYYY	Country	Name	Classification
	N					
	O					
	P					
	Q					
	R					
	S					
	T					

NON-PATENT DOCUMENTS

*		Include as applicable: Author, Title Date, Publisher, Edition or Volume, Pertinent Pages)
	U	Chemical Abstracts Accession Number 1986:571530 HCAPLUS; "Dehydrohalogenation reaction using hindered lithium dialkylamide bases", By Kopka et al., Dep. Chem, Michigan State Univ. USA (1986).
	V	Chemical Abstracts Accession Number 2000:790762, "Liquid precursors for CVD formation of alkali metal compounds such as oxides", Gordon et al. Presentent and Fellows of Harvard College, USA (2000).
	W	
	X	

*A copy of this reference is not being furnished with this Office action. (See MPEP § 707.05(a).)
Dates in MM-YYYY format are publication dates. Classifications may be US or foreign.

Joe Anthony 12/03/04